

AIXTRON and IRUJA Co. Ltd. Sign Joint Venture Agreement (October 24, 2018)



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AIXTRON and IRUJA: Joint Venture in APEVA

AIXTRON

- Innovative Organic Vapor Phase Deposition (OVPD) Technology
 - Highly Efficient Deposition of Organic Materials
 - Proven Path for Scaling
 - Building on AIXTRON Track Record in Thin Film Vapor Phase Deposition



- Well-Established Automation & Handling Technology
 - Well proven in the Display Industry, Well known for the Outstanding Reliability
 - Market Leader in Sputtering Technology for OLED with well established Customer Relationships
 - Manufacturing Partner in Korea: High Quality Local Supply Chain and Resources



APEVA: A Complete OLED Deposition System Provider

OVPD Deposition Line*





- L _ Automation & Handling
- Fully Automated OLED Deposition Lines and Fab Integration as a Complete System Provider
- Innovative Deposition Technology with
 - Higher Efficiency of OLED Material Deposition
 - Mixing and Doping of Materials via Multiple Material Deposition in One Chamber
 - Maintaining the Delicate Organic Material Properties improving Lifetime







APEVA: Current Status and Future Plans

- ✓ Closing of the Joint Venture Agreement: Expected During 2018
- ✓ IRUJA: Up to 20% Equity Stake in APEVA over the Next Few Years

✓ APEVA Operations in both Germany and South Korea

- Germany: Deposition Technology Development
- South Korea: Automation & Handling Technology, Manufacturing, Local Support Close Proximity to Major OLED Customers

✓ APEVA Progress

- Gen1-Size Prototype: Operating at Customer Facility for more than a Year
- Gen2-Size Prototype: Currently being installed in Customer Facility
- GenX-Size Prototype: Order for Production-Size OLED Deposition Chamber (e.g. Gen6 or larger) expected to be received in 2019, following the Successful Qualification of the Gen2-Size Prototype
- GenX-Size Full Production Line: Orders expected once the Scaling to GenX is proven to work (2020+)

